

Docket No.: M4065.0706/P706
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Jiutao Li et al.

Application No.: 10/712,106

Confirmation No.: 8216

Filed: November 14, 2003

Art Unit: 1753

For: SILVER SELENIDE SPUTTERED FILMS
AND METHOD AND APPARATUS FOR
CONTROLLING DEFECT FORMATION IN
SILVER SELENIDE SPUTTERED FILMS

Examiner: R. G. McDonald

RESPONSE TO RESTRICTION REQUIREMENT

MS Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

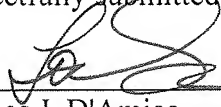
Dear Sir:

In response to the restriction requirement set forth in the Office Action mailed June 25, 2007, Applicants hereby elect Group I, claims 1-84, for continued examination without traverse.

The Examiner has required restriction between Group I, claims 1-84, drawn to a method and apparatus for sputtering; or Group II, claims 85 and 86, drawn to a silver selenide film. Applicant has elected Group I, claims 1-84, for continued prosecution without traverse.

Dated: July 23, 2007

Respectfully submitted,

By 

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